



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

re application of

: Docket No.: CV-0044
Previous Docket No. CC-0654

MARTIN A. PUTNAM ET AL

: Group No.: 2872

Serial No.: 10/661,116

: Confirmation: 6433

Filed: September 12, 2003

Title: Method of Manufacturing of a Diffraction Grating-based Optical Identification Element

Commissioner of Patent and Trademarks
P.O. Box 1450
Alexandria, VA 22313

INFORMATION DISCLOSURE STATEMENT

Dear Sir:

Applicants submit herewith references in accordance with 37 CFR 1.56 and 37 CFR 1.97(b)(3) which is before the mailing date of a first Office action on the merits.

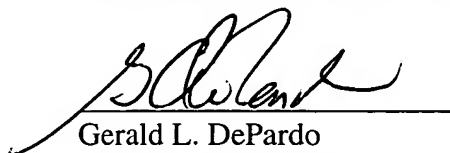
Additionally, each item of information contained in the information disclosure statement was cited in a communication from a foreign patent office in a counterpart foreign application. A copy of the communication from the foreign patent office, i.e. the International Search Report, is also enclosed.

Also enclosed is form PTO1449 listing the cited reference.

Please charge any additional fees or credit overpayment to Deposit Account No. 50-2994, Order No. CV-0044.

Respectfully submitted,

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Form PTO-1449

U.S. Department of Commerce
Patent and Trademark OfficeAttorney Docket No.
CC-0654 (CV-0044)

Serial No. 10/661,116

Applicant:
Martin A. Putnam et alFiling Date:
September 12, 2003Group:
2872

Information Disclosure Citation

(Use several sheets if necessary)

U. S. PATENT DOCUMENTS

Examiner Initial	Document Number	Date	Name	Class	Subclass	Filing Date If Appropriate
	6 0 3 5 0 8 2	3/00	Murphy et al			

FOREIGN PATENT DOCUMENTS

Examiner Initial	Document Number	Date	Country	Class	Subclass	Translation Yes/No
	0 7 9 8 5 7 3	10/97	European			

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

Examiner

Date Considered

*Examiner: Initial if citation considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of the form with next communication to applicant.